PATENT COOPERATION TREATY

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INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

. (Chapter II of the Patent Cooperation Treaty)

(PCT Article 36 and Rule 70)

App	plicant's or agent's file i	reference	T			
SMC 60622WO		FOR FURTHER A	CTION	See Form PCT/IPEA/416		
I		International filing date 01.10.2004	(day/month/year)	Priority date (day/month/year) 25.10.2003		
			<u> </u>		20.10.2000	
	mational Patent Class 3F1/02, C09D11/0		ational classification and I	PC	:	
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1.	This report is the Authority under A	international pre rticle 35 and tran	liminary examination re smitted to the applicar	eport, established by	v this International Preliminary Examining e 36.	
. 2.	This REPORT co	nsists of a total c	of 5 sheets, including t	his cover sheet.	·	
3.	This report is also	accompanied b	y ANNEXES, comprisi	ng:		
			the International Bure	· ·		
	sheets of the description, claims and/or drawings which have been amended and are the basis of this report and/or sheets containing rectifications authorized by this Authority (see Rule 70.16 and Section 607 of the Administrative Instructions).					
	☐ sheets	s which supersec	le earlier sheets, but w	hich this Authority o	onsiders contain an amendment that goes	
	beyon	d the disclosure emental Box.	in the international app	olication as filed, as	indicated in item 4 of Box No. I and the	
	b. (sent to the	e International B	ureau only) a total of (i	ndicate type and nu	mber of electronic carrier(s)) , containing a	
	sequence listing and/or tables related thereto, in computer readable form only, as indicated in the Supplemental Box Relating to Sequence Listing (see Section 802 of the Administrative Instructions).					
	BOX Helati	ng to dequence	Listing (see Section bo	2 of the Administrat	ive instructions).	
4.	This report contai	ns indications re	lating to the following it	tems:	•	
	⊠ Box No. I	Basis of the opin	nion			
	_	Priority				
		•	ent of opinion with rega	ard to novelty, inven	tive step and industrial applicability	
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	☑ Box No. V	Reasoned stater applicability; cita	ment under Article 35(2 tions and explanations	2) with regard to nove supporting such sta	elty, inventive step or industrial atement	
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	☐ Box No. VIII	Certain observat	ions on the internation	al application		
Date	e of submission of the	demand		Date of completion of	of this report	
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22.0	22.08.2005		12.10.2005			
	Name and mailing address of the international			Authorized Officer		
preli	preliminary examining authority: European Patent Office				J. 5	
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INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

International application No. PCT/GB2004/004186

	Box No. I	Basis of the report		
í.	With regar	d to the language , this report is based on the international application in the language in which it was otherwise indicated under this item.		
	which □ int □ pu	eport is based on translations from the original language into the following language, is the language of a translation furnished for the purposes of: ernational search (under Rules 12.3 and 23.1(b)) blication of the international application (under Rule 12.4) ernational preliminary examination (under Rules 55.2 and/or 55.3)		
2.	With regard to the elements* of the international application, this report is based on <i>(replacement she)</i> have been furnished to the receiving Office in response to an invitation under Article 14 are referred to report as "originally filed" and are not annexed to this report):			
	Description	n. Pages		
	1-21-	as originally filed		
	Claims, Nu	mbers		
	1-21	received on 22.08.2005 with letter of 27.07.2005		
	□ a seq	uence listing and/or any related table(s) - see Supplemental Box Relating to Sequence Listing		
3.	☐ the	mendments have resulted in the cancellation of: e description, pages e claims, Nos. e drawings, sheets/figs e sequence listing (specify): y table(s) related to sequence listing (specify):		
4.	had not be Suppleme. the the the the the	This report has been established as if (some of) the amendments annexed to this report and listed below d not been made, since they have been considered to go beyond the disclosure as filed, as indicated in the applemental Box (Rule 70.2(c)). the description, pages the claims, Nos. the drawings, sheets/figs the sequence listing (specify): any table(s) related to sequence listing (specify):		
٠	* If it	em 4 applies, some or all of these sheets may be marked "superseded."		

INTERNATIONAL PRELIMINARY REPORT ON PATENTABILITY

International application No. PCT/GB2004/004186

Box No. V Reasoned statement under Article 35(2) with regard to novelty, inventive step or industrial applicability; citations and explanations supporting such statement

1. Statement

Novelty (N)

Yes: Claims

1-20

No: Claims

21

Inventive step (IS)

Yes: Claims

1-20

1-29

...,

No: Claims

21

Industrial applicability (IA)

Yes: Claims

No: Claims

2. Citations and explanations (Rule 70.7):

see separate sheet

Re Item V.

1) The following documents are referred to in this communication:

D1: EP 0 659 038 A (CANON KK) 21 June 1995 (1995-06-21)

D2: WO 95/23244 A (MUHL JONATHON; UNIV EDINBURGH (GB)) 31 August

1995 (1995-08-31)

D3: US 4 767 489 A (LINDNER FREDERICK H) 30 August 1988 (1988-08-30)

D4: US-A-4 536 468 (AKAIKE AKIHIKO ET AL) 20 August 1985 (1985-08-20)

- 2) Claim 21 defines etched metal articles obtainable by the present process. The articles as such are conventional. The present invention concerns a process where the resist used is of primary importance. The resist is not required to be present in the products of claim 21. It is also clear to a skilled person that as a rule the resist will not persist in the final product. Nothing in the application suggests that etched articles produced by the present process are distinguishable from etched articles obtained using other processes such as the processes of documents D1-D4 or processes using conventional photolithographic techniques. Thus the subject-matter of claim 21 is thus both trivial and not novel (Article 33(2) PCT).
- 3) Document D1 (see page 3, line 1 to page 6, line 29 and claims) discloses etching resist compositions which are applied from ink-jet printers and hardened by solvent (typically water) removal. The composition has a viscosity below 10 cPs and contains a resin with an acid value of at least 35 neutralised with a base and optionally a surfactant and/or a colorant. Bases mentioned include polyamines. Resins neutralised with polyamines will contain chelating groups. The resist is strippable by a strong alkali

The subject-matter of claims 1-20 is novel with respect to the disclosure of document D1 because the claims require that the resist is a hot melt ink. Hot melt inks have different chemical composition from the resist disclosed in document D1.

3.1) Resists for use in etching metals based on hot-melt inks for application by ink-jet printing are disclosed in documents D2 (whole document) and D3 (column 6, line 43 - column 7, line 21 and claims). Documents D2 and D3 do not disclose the use of

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International application No.

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resins containing chelating groups. Thus the subject-matter of claims 1-20 is also novel with respect to the disclosure of documents D2 and D3.

The problem in view of these documents is to provide processes using a resist which enables a very fine etch pattern to be obtained and that is readily stripped.

It is known that when forming resist patterns on a substrate by lithographic printing similar problems may be solved by the use of an resist containing a resin with chelating groups (see document D4, column 1, lines 1-37, claims and examples). Document D4 does not however relate to hot-melt inks, or inkjet printing and uses resists which chemically differ considerably from hot-melt inks. It would thus not be obvious to a skilled person to consult document D4 when seeking to solve the present problem in hot melt inks.

Thus the subject-matter of claims 1-20 is considered to be inventive (Article 33(3) PCT).

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CLAIMS

- A process for etching a metal or alloy surface which comprises applying a hot melt etch-resist ink by ink jet printing to selected areas of the metal or alloy solidifying the etch-resist ink by cooling and then removing the exposed metal or alloy by a chemical etching process wherein the hot melt etch-resist ink comprises the components:
 - A) 60 to 100 parts carrier vehicle comprising one or more components which contain at least one metal chelating group;
 - B) 0 to 40 parts colorant; and
 - C) 0 to 5 parts surfactant;

wherein the ink has a viscosity of not greater than 30 cPs (mPa.s) at the firing temperature, all parts are by weight and the total number of parts A)+B)+C) = 100.

- 2. A process as claimed in claim 1 wherein the metal chelating group(s) are selected from the group consisting of ketoximines; acetarylamides; hydroxy silanes and alkoxy silanes; aryl or heteroaryl hydroxides; N-containing heterocycles; acid anhydrides; β-diketones, β-keto esters, β-keto aldehydes, β-keto heterocycles; and acid groups.
- 3. A process as claimed in claim 1 wherein the metal chelating group(s) are selected from the group consisting of imidazoles, benzimidazoles, triazoles, benzimizoles, thiazoles and isothiazoles.
 - 4. A process as claimed in claim 1 wherein the metal chelating group(s) are selected from the group consisting of β -diketones, β -keto esters, β -keto aldehydes and β -keto heterocycles.
 - 5. A process as claimed in claim 1 wherein the metal chelating group(s) are acid groups.
- 30 6. A process as claimed in claim 5 wherein the acid groups are selected from the group consisting of carboxylic acid, phosphoric acid, polyphosphoric acid, phosphoric acid, sulphuric acid and sulphonic acid groups.
 - 7. A process as claimed in claim 5 wherein the acid groups are carboxylic acid groups.
 - 8. A process as claimed in claim 1 wherein the carrier vehicle comprises two or more types of metal chelating groups wherein at least one of the metal chelating groups is an acid group and at least one of the metal chelating groups is not an acid group.

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- A process as claimed in any one of claims 1 to 8 wherein the colorant is a pigment.
- 10. A process as claimed in any one of claims 1 to 9 wherein the colorant is blue.
- 11. A process as claimed in any one of claims 1 to 10 wherein the etch-resist ink has been filtered through a filter having a pore size of 1 micron.
 - 12. A process as claimed in any one of claims 1 to 11 wherein the viscosity of the etch-resist ink is from 8 to 15 cPs (mPa.s) at the firing temperature.
 - 13. A process as claimed in any one of claims 1 to 12 wherein the firing temperature is from 50 to 150°C.
- 14. A process as claimed in claim 1 wherein at least one component of the carrier vehicle contains at least one acid metal chelating group and the etch-resist ink has an acid value from 40 to 150mg KOH/g.
 - 15. A process as claimed in any one of claims 1 to 14 wherein the metal or alloy is iron or a ferro alloy.
 - 16. A process as claimed in claim 1 wherein the carrier vehicle comprises a wax or polyamide polymer or a mixture thereof.
 - 17. A process as claimed in any one of the preceding claims wherein the etching fully penetrates the metal or alloy.
 - 18. A process as claimed in any one of claims 1 to 17 wherein the solidified etch-resist is removed after etching.
- 19. A process as claimed in claim 18 wherein the solidified etch-resist is removed by treatment with an alkaline medium.
 - 20. An etched metal or alloy partially coated with a solidified etch-resist made by the process as claimed in any one of claims 1 to 17.
 - 21. A grid, a filter, a graticule, a mesh, a light chopper disc, a heat sink plate, a heater element, a screen, colour TV mask, a diaphragm, a shim, a gasket, a washer, a spring, a link, a probe, a magnetic recording head, a circuit lead frame, an encoder disc, an item of jewellery, a rule, a scale, a clutch plate, an emitter contact, a micro reactor, a suspension lead, an ink jet nozzle plate, a stencil, a razor foil, a bearing, an edge filter, a logo, a







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nameplate, a decorative plaque, an instrument case, a box, an enclosure and a potentiometer case having a chemically etched surface pattern or design made by a process as claimed in any one of claims 1 to 17.